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Form PTO-1449 (modified)

List of Patents and Publications for Applicant's

INFORMATION DISCLOSURE STATEMENT

MAR 14 2002

(Use several sheets if necessary)

U.S. Patent Documents

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Foreign Patent Documents

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Other Art

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2823

U.S. Patent Documents

Exam. Init.	Ref. Des.	Document Number	Date	Name	Class	Sub- Class	Filing Date if App.
K.M.	A1	4,921,321	5/1/90	Weidman			
K.N.	A2	5,439,780	8/8/95	Joshi et al.			
K.N.	A3						

Foreign Patent Documents

Exam. Init.	Ref. Des.	Document Number	Date	Country	Class	Sub- Class	Translation Yes/No
	B1						

Other Art (Including Author, Title, Date, Pertinent Pages, Etc.)

Exam. Init.	Ref. Des.	Citation
K.N.	C1	Ajey M. Joshi et al., "Plasma Deposited Organosilicon Hydride Network Polymers as Versatile Resists for Entirely Dry Mid-Deep UV Photolithography," <i>SPIE</i> , Vol. 1925, pp. 709-720, January 1993.
K.N.	C2	O. Joubert et al., "Plasma polymerized - dry resist process for 0.25 μm photolithography," <i>J. Vac. Sci. Technol. B</i> 12(6), pp. 3909-3913, Nov/Dec 1994.
K.N.	C3	O. Joubert et al., "Plasma Polymerized Organosilane Network Polymers; High Performance Resists for Positive and Negative Tone Deep UV Lithography," <i>SPIE</i> , Vol. 2195, pp. 358-371, May 1994.
K.N.	C4	T. W. Weidman et al., "Applications of Plasma Polymerized Methylsilane as a Resist and Silicon Dioxide Precursor for 193 and 248 nm Lithography," <i>SPIE</i> , Vol. 2438, pp. 496-512, June 1995.
K.N.	C5	Timothy W. Weidman and Ajey M. Joshi, "New photodefinable glass etch masks for entirely dry photolithography: Plasma deposited organosilicon hydride polymers," <i>Appl. Phys. Lett.</i> 62(4), pp. 372-374, January 25, 1993

Examiner:

Khurana

Date Considered:

1/16/04

EXAMINER: initial if reference considered, whether or not citation is in conformance with MPEP609. Draw line through citation if not in conformance and not considered. Include copy of this form with next communication to applicant.

Form PTO-1449 (modified)

Atty. Docket No.
97-0008D1Serial No.
10/015,434INFORMATION DISCLOSURE STATEMENT
(Use several sheets if necessary)Applicant
Bradley J. HowardFiling Date:
December 13, 2001Group:
Unknown 2823U.S. Patent Documents
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U.S. Patent Documents

Exam. Init.	Ref. Des.	Document Number	Date	Name	Class	Sub Class	Filing Date if App.
K.N.	A3	5,215,861	6/1/93	Augustino et al.			
K.N.	A4	4,978,594	12/18/90	Bruce et al.			
K.N.	A5	5,885,751	3/23/99	Weidman et al.			

Foreign Patent Documents

Exam. Init.	Ref. Des.	Document Number	Date	Country	Class	Sub Class	Translation Yes/No

Other Art (Including Author, Title, Date Pertinent Pages, Etc.)

Exam. Init.	Ref. Des.	Citation

Examiner: KhrienguyenDate Considered: 6/16/04

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